

FORM PTO-1449

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10/525,724Applicant
Yoshiaki SUZUK et al.Filing Date
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1743INFORMATION DISCLOSURE STATEMENT
BY APPLICANT

(Use several sheets if necessary)

U.S. PATENT DOCUMENTS

EXAMINER INITIAL		DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
/RZ/		5 1 5 2 7 8 3	10/06/92	SUZUKI et al.			
/RZ/		5 3 0 8 7 0 4	05/03/94	SUZUKI et al.			
/RZ/		6 0 5 1 7 5 1	04/18/00	SIOHANSI et al.			
/RZ/		6 8 7 2 7 5 9	03/29/05	SUZUKI et al.			

FOREIGN PATENT DOCUMENTS

		DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	TRANSLATION YES NO
/RZ/	2000	- 1 2 9 0 1 5	05/09/00	JAPAN			
/RZ/	7	- 5 0 0	01/06/95	JAPAN			
/RZ/	5	- 2 0 8 0 4 2	08/20/93	JAPAN			
/RZ/		1 2 5 2 9 0 2	10/30/02	E.P.O			

OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)

/RZ/	1	Yoshiaki SUZUKI et al., "Ion Beam Irradiated Expanded Polytetrafluoroethylene for the Development of Dura Mater", IONICS, Vol. 27, No. 7, pp. 3-11 (2001).
/RZ/	2	Yoshiaki SUZUKI et al., "Biomedical Application of Ion Beam Irradiated Polymeric Materials", IONICS, Vol. 25, No. 6, pp. 47-54 (1999).
/RZ/	3	Masayoshi IZUKAWA et al., "Nerve Cell Attachment Property of Absorbable Poly-Lactic-Acid Modified by Carbon Negative-Ion Implantation", J. Vac. Soc. Jpn., Vol. 45, No. 6, pp 514-518 (2002).
	4	Yoshiteru SUZUKI et al., "Ion Beam Ni Yoru ePTFE Jinko Komaku No Kaishitsu -Soshiki Oyobi Fibrin Nori Saibo Gecchakusei No Fuyo-", The Society of Polymer Science, Japan Yokosha, Vol. 52, No. 5, pp. 1152 (2003)
	5	Noriyoshi TAKAHASHI et al., "Ion Beam Shosha Ni Yoru ePTFE Jinko Komaku No Kaiyo", Three Beams Gijutsu Ni yoru Hyomen Kaishitsu to Kaiseki Yokosha Riken Symposium, Heisei 15 Nen, pp. 24 (2003).
/RZ/	6	English language Abstract of JP 2000-129015.
/RZ/	7	English language Abstract of JP 7-500.

EXAMINER /Ramsey Zacharia/

DATE CONSIDERED 01/15/2008

*EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP 609; draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.